

Preparation and Properties of $\text{Mg}(\text{B}_{1-x}\text{C}_x)_2$ Using Carbon Chemical Vapor Coated Boron

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Abstract—Promising initial results on bulk $\text{Mg}(\text{B}_{1-x}\text{C}_x)_2$ prepared with carbon doped boron are presented. Carbon doping is achieved by reaction of ethylene gas on boron powder using a stainless steel tube furnace, a technique suitable for industrial scale processing. The nominal amount of doping was controlled by varying the reaction time with a fixed volume of ethylene gas, and the actual carbon uptake was determined by weight change after the reaction. The amount of carbon substitution x in the $\text{Mg}(\text{B}_{1-x}\text{C}_x)_2$ was found using the angular shift in the (100) x-ray reflection. Carbon substitution by the full nominal content in the C doped precursor boron was obtained for doping up to 7.2at%, as shown by a a -axis compression consistent with that of carbon doped single crystals. The critical current density of the 4at% C doped sample for temperatures at 20–30 K and fields up to 4 T, relevant to high temperature applications, was significantly higher than those in the published literature. The J_C of a 10wt% nano-SiC doped sample, used as a comparative benchmark, was found to be lower than the C doped sample at field below 2 T, but to reduce slower at higher fields. Structure analysis of the SiC doped sample revealed a coexistence of two C substitution levels of 2.25% at and 5.25% at.

Index Terms—Boron powder, carbon doping, critical current, MgB_2 superconductor.

I. INTRODUCTION

THE 39 K transition temperature of MgB_2 allows liquid-cryogen free technology be used in the 20–30 K range. Currently NbTi is widely used in many superconducting applications, but requires complex and expensive Liquid He cooling. A realistic MgB_2 market will open-up if the critical current in field, $J_C(B)$, performance of MgB_2 can be improved to a level where it will compete with NbTi, with a lower cost and smaller size of the cryogenics.

Doping with carbon has so far shown the most promising improvements in the field dependence of the critical current density $J_C(B)$, for both wire and bulk MgB_2 conductors, [1], [2]. The improvements in $J_C(B)$ are attributed to lattice defects increasing the upper critical field H_{C2} . The method of C distribution in the precursor with uniformity at nanometer scale is therefore essential in order to take full advantage of bulk property enhancements attributed to crystalline defects.

At present carbon has been added successfully by high speed milling, [1] and grinding, [2]. However both methods have the drawback of requiring precursor powder of a small grain size, typically sub-micron nano-particles, which forms

soft agglomerates due to the overriding effect of electrostatic attraction at the nanometer length scale. Such agglomerates, difficult to break mechanically, are the source of inhomogeneity detrimental to achieving the uniform doping required. When synthesized to MgB_2 the dopants must be transported by diffusion, hence require a higher reaction temperature that may not be desirable for the optimal $J_C(B)$ performance. In addition the long milling times, required for good mixing, of the very hard MgB_2 grains with a micro-hardness around 1000 kgmm^{-2} comparable to that of SiC [3], significantly increase the risk of contamination by the milling media.

In this paper, we describe a method of *intrinsically homogeneous* carbon loading by chemical vapor deposition (CVD) of carbon on to the boron precursor powder. Such a method presents two advantages. Firstly it allows the dopant to be distributed without contamination. Secondly the dopants are distributed evenly to every individual precursor grains so that a homogeneous nanometer scale distribution can be achieved with a nano-boron powder. The realization of such a CVD carbon loading using ethylene gas in a closed system is described in the paper. Structure analysis was used to determine the level of C substituted in bulk MgB_2 samples prepared with the carbon loaded boron powder by the liquid infiltration technique, [4]. The critical current density and its field dependence $J_C(B)$ were also measured and compared with doping by SiC nano-particles. The comparison firstly serves to highlight the improvements in critical current relative to another dopant, for the same liquid infiltration technique, and secondly demonstrates that doping by CVD results in more homogenous crystalline properties.

II. EXPERIMENTAL

A. Doping of MgB_2 Precursor

A purpose built stainless steel tube furnace was used for the chemical vapor deposition of carbon on boron powder. Ethylene gas was introduced after the furnace tube was evacuated by a turbo-molecular vacuum pump to 10^{-4} mBar. Boron powder, with a grain size of $< 1 \mu\text{m}$, and a purity of 99.9% was treated in ethylene gas for fixed periods. The mass of the boron powder was measured before and after the process and the mass of C deposited estimated from the mass gain. The powders were then examined in a scanning electron microscope (SEM) for morphology analysis. The precursor boron powder CVD coated with carbon is referred as C-CVD boron in the following text, and the corresponding samples as C-CVD MgB_2 .

The nano-SiC doped boron was prepared by mixing the powders together in methanol slurry under ultrasound for several hours, then slowly heated up to 100°C for the removal of methanol by evaporation.

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B. Bulk MgB_2 Samples

With the C doped and SiC doped precursors MgB_2 bulk was made by the liquid infiltration technique, [4]. Boron pellets of 12 mm diameter and 15 mm thickness were pressed into Ta lined Fe crucibles. For each sample, a magnesium rod was placed on the top of the pellet. Then the lid of the Fe crucible was closed firmly above the Mg rod so that no air gap remained, and finally the crucible was sealed by arc welding. Excess Mg of about 10% was used to compensate for any loss due to reaction with the Fe and ensure there is sufficient Mg to complete the formation of magnesium diboride. The Fe crucibles were placed in a vacuum furnace and heated to 850°C for 10 h then furnace cooled to room temperature.

C. Characterization

The top face of the reacted pellets were ground back ~ 3 mm to present a core surface for $\theta - 2\theta$ powder x-ray diffraction (XRD) analysis. The magnetic hysteresis ΔM of small slabs, cut with a diamond wheel to a typical dimensions of $\sim 3 \times 1 \times 0.25$ mm³, were measured in fields up to 9 T and temperatures between 5 K and 30 K using a vibrating sample magnetometer (VSM) in a *Quantum Design Physical Property Measurement System*. The critical current density was determined using $J_C = 20\Delta M/d$, where d is the thickness of the slab.

III. RESULTS AND DISCUSSION

A. Boron Powder CVD Coated With Carbon

On opening of the crucibles all samples were fully reacted with no Mg rod remaining, and were removed as hard solid pucks, without large cracks or other macro-scale defects.

Carbon deposition on the boron was confirmed by Energy Dispersive Analysis, which showed no significant changes in the powder morphology shown by Secondary Electron images at a resolution of ~ 0.1 μm .

B. Structure Analysis of C-CVD MgB_2

Due to a relatively low reaction temperature of 850°C, the MgB_2 pellets obtained were of high phase purity with some Mg inclusions but no significant secondary MgB_2 phases detected by standard XRD analysis. X-ray diffraction of the reacted samples, (Fig. 1), shows increasing C doping shifts the (100) peak, to higher angles, whilst the (002) peak position remains comparatively unchanged. Both peaks broaden considerably with increasing C content.

The change in the a-axis lattice parameter Δa , derived from the (100) peak, is plotted in Fig. 2 against the nominal doping fraction x in the precursor power of $\text{Mg} + 2(\text{B}_{1-x}\text{C}_x)_2$, calculated from the deposited mass of C, alongside data from the literature [1], [2], [5]. Full carbon substitution at the nominal doping level is confirmed by the agreement of Δa between C-CVD MgB_2 sample and C doped single crystal [5]. Therefore the actual doping achieved in $\text{Mg}(\text{B}_{1-x}\text{C}_x)_2$ equates to the nominal doping fraction x in the precursor powder. The advantage of the present method of C distribution by CVD coating of B powder is evident when compared with mechanical carbon doping by grinding [2] and high speed ball milling [1], which only achieved partial substitution of the nominal doping content.

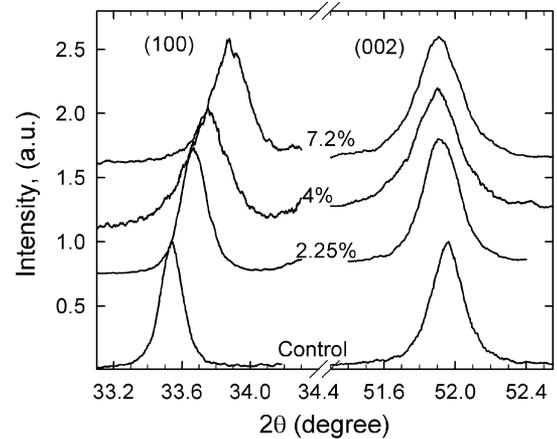


Fig. 1. Reflection of (100) from XRD of the C-CVD doped samples with increasing nominal doping percentage of C. Shift of the reflection to higher angles corresponds to a decreasing a-lattice constant (left), whilst the (002) peak (right) remains comparatively unaffected.

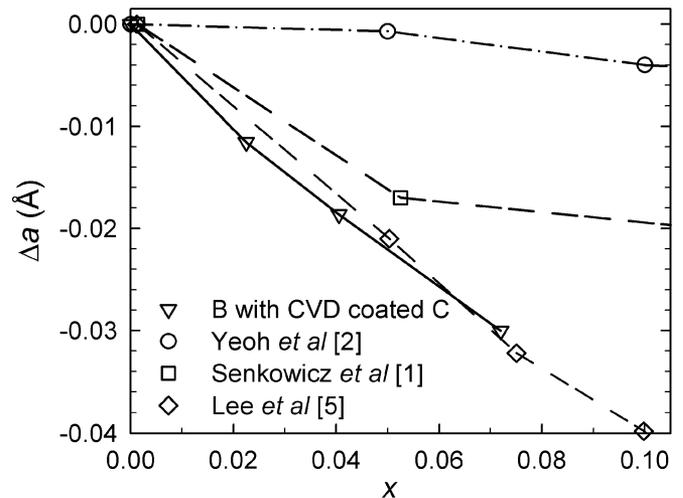


Fig. 2. The change in the a-axis lattice constant, Δa calculated from the (100) reflection, against nominal doping fraction x , from $\text{Mg}(\text{B}_{1-x}\text{C}_x)_2$. The compression of a-axis Δa of the C doped samples using C-CVD boron are in good agreement with those of C-doped single crystals [5], indicating full substitution of B by the nominal C content in the MgB_2 lattice. Partial substitution obtained with milling, [1] and grinding [2] are shown for comparison.

As no reduction in C substitution was found up to 7.2% at, the technique looks to have the potential for even higher C doping towards the theoretical saturation limit. The broadening of both (100) and (002) reflections at higher C doping may be attributed to strain and small grain size. It has been suggested that the lattice disorder is a consequence of the C prohibiting the crystal growth of the MgB_2 [1].

C. Critical Current Density of C-CVD MgB_2

Fig. 3 shows the critical current density as a function of magnetic field at different temperatures between 5 K and 30 K. In the log-log plot, $J_C(B)$ varies with $\sim 1/B$ at low fields and then reduces sharply with $\sim 1/B^4$ or exponentially at higher fields. The transition field from one behavior to the other increases with reducing temperature, e.g. 0.75 T at 30 K and 4.0 T at 5 K. Compared with other C doped MgB_2 samples [1], [2],

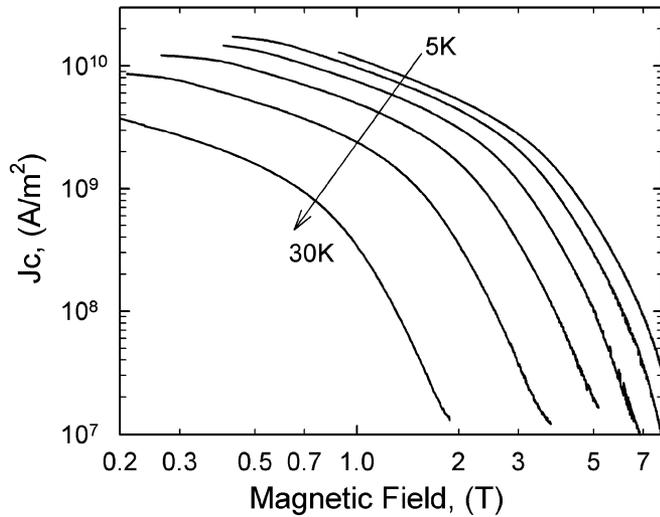


Fig. 3. Critical current density for 4% at C doped sample $\text{MgB}_{0.96}\text{C}_{0.04}$ as a function of magnetic field at temperatures between 5 K and 30 K incremented steps of 5 K.

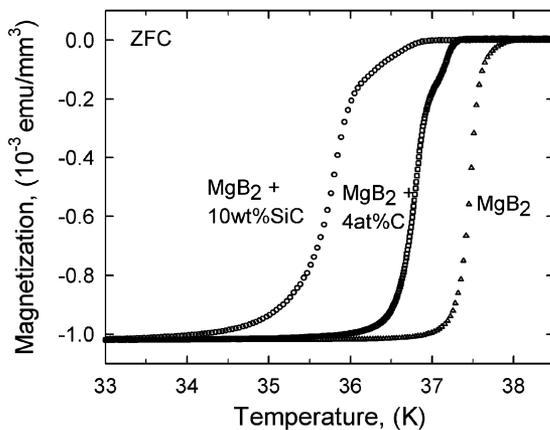


Fig. 4. Zero-field-cooled DC magnetisation of samples made from pure Boron, and Boron doped with 4% C-CVC, and 10wt% nano SiC doped.

the J_C of the C-CVD MgB_2 samples exhibit is most improved at high temperatures and low/intermediate fields. In particular, the J_C at 20–30 K and in fields up to 4 T is among the highest of any MgB_2 preparation in the published literature. A better performance principally at high temperatures and lower field indicates a clean C substitution without significant formation of secondary phases, as also shown by the XRD data in Fig. 1. It is also noted that the critical temperature T_C of the 4% at C-CVD sample was at 36.6 K (Fig. 4), which is significantly higher than those at 30–33 K for C doped single crystals samples [4], [5] with the same a-lattice reduction of 0.02 Å. The apparent non-commensurate nature of T_C with a-axis lattice parameter may be symptomatic of a separation of structural shift and electronic doping, and will be a topic of further investigation. At this early stage in this work it is worth pointing out that the single crystals were grown at 1600–1900°C, whilst the C-CVD samples in this work were reacted at 850°C. It is possible that the reaction temperature affects nature of the C-B and C-Mg bonds.

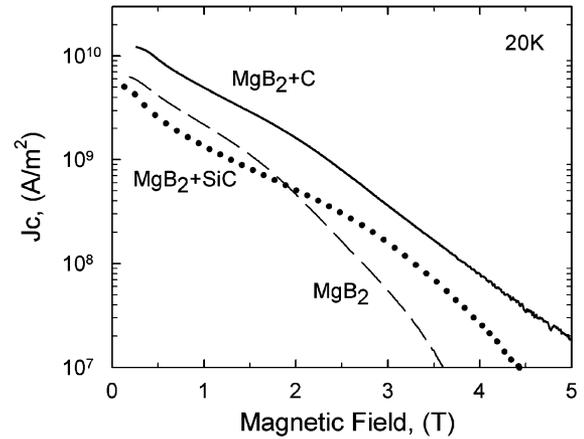


Fig. 5. Comparison of critical current at 20 K for samples made from pure boron, and boron doped with 4% C-CVD, and 10wt% nano SiC doped.

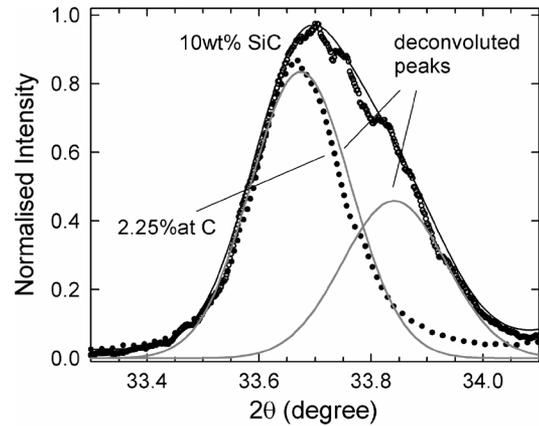


Fig. 6. The (100) reflection of the 10wt% nano-SiC, (symbols), deconvoluted, reveals it is composed of two reflections, (dashed lines), the low angle is near identical to the measured 2.25% C-CVD sample, (solid line), and the higher angle peak can be interpreted from a linear interpolation of C-CVD doped data in Fig. 2 as 5.25% C inclusion.

D. Comparison Between Carbon Doping by C-CVD Boron and Nano-SiC

In Fig. 5 the $J_C(B)$ at 20 K of the 4% C-CVD doped MgB_2 sample is compared with that of 10wt% SiC doped sample, with the un-doped control sample shown as the reference. The C-CVD doped sample has a better performance throughout the field range. It is noted, however, that the SiC doped sample showed a slower J_C reduction between 0.5 T and 3 T, possibly indicating contribution of a different pinning mechanism in this field range.

It has been suggested [1] that improvements in $J_C(B)$ by SiC doping are due to C doping of the MgB_2 . While the (100) reflection of the SiC doped sample shown in Fig. 6 is shifted to a high angle as expected, the broad non-symmetric peak is significantly different from those found in the C-CVD samples. Two underlying Gaussian peaks were found by χ^2 fitting (solid line). The peak at lower angle is very close to that of 2.3% at C-CVD doping (solid dots), while the higher angle peak corresponds to a C doping percentage of about 5% at using the C-CVD and single crystal data shown Fig. 2. The split of the (100) peak into two peaks can be interpreted as an inhomogeneous lattice structure

with non-uniform C doping by SiC. Different C substitution level in SiC doped samples is most likely the result of the inhomogeneity in nano-SiC distribution in the precursor powder. In contrast, the relatively clean XRD found in C-CVD samples makes it ideal to identify the contribution directly resulted from lattice substitution by C, reducing the complications of a dirtier system such as SiC doping. A broad two step superconducting transition in SiC doped sample (Fig. 4) with an onset T_c as high as 36.4 K also underlines multiple C doping levels suggested by the XRD data.

Further work to measure the $J_C(B)$ of samples made with a range of C-doping percentages will allow the possible interpretation of the SiC doped sample into two parallel current paths of different C doping levels.

IV. CONCLUSION

Initial results on the physical and magnetic properties of MgB_2 bulk made from C-CVD doped B. Full inclusion of C has been demonstrated for samples of $\text{Mg}(\text{B}_{1-x}\text{C}_x)_2$ $x = 0.02, 0.04, \text{ and } 0.07$. At this stage the optimum percentage of C for maximum $J_C(B)$ has not yet been found, but already the

4% sample has the highest critical currents available in the literature in the 20–30 K, 1–4 T range, where the first MgB_2 applications are currently anticipated. By comparing the XRD and J_c properties of the C-CVD doped to a nano-SiC doped sample, the dispersion of C is shown to be better by the CVD route and the critical current consistently higher.

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